

IN THE CLAIMS:

Please amend the claims as indicated below. No new matter is introduced.

1. (Previously Presented) An optoelectronic sensor for demodulating a modulated photon flux (50) comprising:
 - 5 a semiconductor region (10);
at least two collecting zones (20, 22) present in the semiconductor region (10) and serving for collecting and tapping off minority carriers (11) generated when said modulated photon flux (50) penetrates into the semiconductor region (10), the collecting zones (20, 22) being doped inversely with respect to the semiconductor region (10);
10 characterized by at least two control zones (32, 34) introduced in the semiconductor region (10) and serving for generating a drift field in a manner dependent on a control voltage that can be applied to the control zones (32, 34), the control zones (32, 34) being of the same doping type as the semiconductor region (10).
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2. (Original) The optoelectronic sensor as claimed in claim 1, wherein the semiconductor region (10) is situated above or in a semiconductor substrate (12), which is doped more highly than the semiconductor region (10).
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3. (Original) The optoelectronic sensor as claimed in claim 1, wherein the semiconductor region (10) is applied on a dielectric (12).
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4. (Original) The optoelectronic sensor as claimed in claim 1, wherein the control zones (32, 34) are at a greater distance from the midpoint of the sensor than the collecting zones (20, 22).
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5. (Original) The optoelectronic sensor as claimed in claim 1, wherein the semiconductor region (10) is p-doped.
6. (Previously Presented) The optoelectronic sensor as claimed in claim 1, wherein the collecting zones (20, 22) are diffused.

7. (Original) The optoelectronic sensor as claimed in claim 1, wherein the collecting zones (20, 22) are produced by local charge transfers in the semiconductor region (10).

8. (Cancelled)

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9. (Cancelled)

10. (Cancelled)

10 11. (Cancelled)

12. (Cancelled)

13. (Previously Presented) A measuring device in particular for 3D distance
15 measurement, comprising

at least one optoelectronic sensor as claimed in claim 1,

an optical transmitter for generating a modulated photon flux having a
predetermined phase,

20 a device (60) for generating a control voltage, the phase of the control voltage
being in a fixed relationship with the phase of the photon flux generated by the
transmitter, and

an evaluation device (40, 42) assigned to the collecting zones (20, 22) and serving
for determining the amplitude and the phase of the modulated photon flux with respect to
the phase of the control voltage.

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14. (New) The optoelectronic sensor as claimed in claim 1, wherein the collecting zones (20, 22) are formed as Schottky diodes.

30 15. (New) The optoelectronic sensor as claimed in claim 1, wherein the semiconductor region (10), more than one collecting zone pair is embedded between the
at least two control zones (32, 34) or two capacitive elements (35, 36, 37, 38).